

Notice of References Cited	Application/Control No. 10/800,195	Applicant(s)/Patent Under Reexamination DAI ET AL.	
	Examiner Sin J. Lee	Art Unit 1752	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-3,816,380	06-1974	Reed, Jr., Samuel F.	526/215
	B	US-			
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	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Dai et al ("Synthesis and Evaluation of Novel Organoelement Resists for EUV Lithography", Proceedings of SPIE, vol.5039 (2003), pg.1164-1172).
	V	Chung et al ("Metallocene-Mediated Olefin Polymerization with B-H Chain Transfer Agents: Synthesis of Chain-End Functionalized Polyolefins and Diblock Copolymers", Macromolecules, vol.34 (2001), pg.8040-8050).
	W	Gabor et al ("Hydrosiloxane Modified Styrene-Diene Block Copolymer Resists", Proceedings of SPIE, vol.1925 (1993), pg.499-506).
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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.